



# ICP-3500E

# Inductively coupled plasma emission spectrometer



EPCC / PRODUCTS / APPLICATION / SOFTWARE / ACCESSORIES / CONSUMABLES / SERVICES

# **Analytical Technologies Limited**

An ISO 9001 Certified Company

www.analyticalgroup.net



ICP-3500E Inductively Coupled Plasma Emission Spectrometer. Light source system adopts solid-state RF generator and end-on viewing mode which has the characteristics of low detection limit,high resolution,stable operation and wide application. Can quickly and accurately detect 70 elements from micro to macro quantity.

# **Application range:**

Widely used in geological, metallurgical, rare earth separation, rare earth magnetic materials, medical and health, environmental, biological, marine, petroleum, chemical, nuclear, agricultural, water quality and other scientific area.

#### Instrument characteristics:

- ICP solid-state RF generator: small size, light weight, high efficiency, automatic matching function, output power stability better than 0.1%, can test samples of organic solution;
- Viewing method: end-on type, with low detection limit;
- Injection system: using stable and reliable Precision Mass Flow Meter. Advanced spray chamber,repeatability RSD can reach <1.0%;
- Automatic protection: water cut-off, gas cut-off, over-flow, overheating, prevent torch from melting, etc.

# **Detection limit <1ppb:**

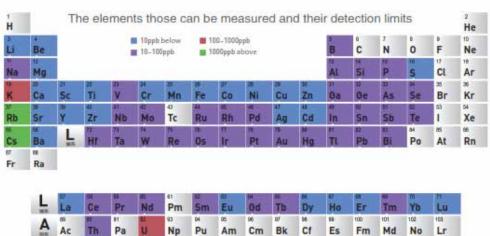
Be, Ca, Mg, Sr, Ba, Y, Sc, Eu, Yb, La, Lu, Co, Fe, ZnHo, Er, Cd, Mn, Ti

# **Detection limit 1-10ppb:**

B、Si、Cr、Ni、Cu、Ga、Zr、Nb、Mo、Ru、Rh、Pd、W、Ir、Pt、Au、Ce、Pr、Nd、Sm、Tb、Al、Gd、Ag、V;

# **Detection limit 10-100ppb:**

P、Ge、As、Se、Rb、In、Sn、Te、Cs、Hf、Ta、Re、Os、Hg、Ti、Pb、Bi、Th、U、Sb





# **Technical specifications:**

RF generator:

Circuit type : Solid state component, passive type

Working frequency : 27.12MHz

Output Power : 700W~1200W

Output power stability : <0.1%

**Optical system:** 

Light path type : Czerny-Turner

Detector : CCD

Focal length : 1000mm

Grating : Ion-etched holographic grating,2400line/mm,

Grating line area (80×110) mm2

Exit, entrance slit : 20µm

Photometric device:

Operating Voltage : -(200~1000 ) V

Current measurement range : 10<sup>-4</sup>~10<sup>-9</sup>A

Stability : <0.05%

Signal acquisition method : V/F conversion

Sample introduction device:

Torch working coil : Inner diameter φ22mm, 3T

Torch : Three concentric quartz torch,φ20mm : Concentric Meinhard nebulizer,φ6mm

Spray chamber : Special high efficiency

Argon flowmeter : Double cylinder swirling compound chamber

a) Plasma gas : (0~20) L/min b) Auxiliary gas : (0~2) L/min c) Carrier gas : (0~2) L/min

**Machine technical specifications:** 

Measuring wavelength range : (190~800) nm

Resolution: ≤0.015nmMeasurement repeatability: RSD≤1.0%Measurement stability: RSD≤2.0%

Representative element detection lower limit : ppb



#### **Datasheet:**

#### 1. Complete machine requirements:

- 1.1 Automatic technology is adopted for plasma excitation and impedance matching, with small reflected power and standing wave ratio not greater than 1.25
- 1.2 The axial observation method is adopted. The lengthened torch tube is used to reduce the fluctuation of the tail flame. The cold cone is placed at the tail flame position to prevent the tail flame from entering the observation hole
- 1.3 Mass flowmeters are used for three plasma gas paths, and computer control is adjustable
- 1.4 The inner diameter of the working coil is small, the energy conversion efficiency is high, the power is 1000w, and the robustness is greater than 9 when the carrier gas is 0.7L/min
- 1.5 A wavelength scanning shall be carried out before the sample measurement to avoid the influence on the measurement accuracy due to the long time measurement wavelength shift.
- 1.6 Upgrade spectral line database, with up to 50000 pieces of data information
- 1.7 Automatic screening function of interference spectrum
- 1.8 Automatic serial communication
- 1.9 Analysis speed: scanning more than 5 elements in one minute
- 1.10 Scanning range: 190~800nm
- 1.11 Scanning mode: turbine vortex rod, driven by computer controlled stepping motor, with the minimum scanning step of 0.0006nm
- 1.12 Wavelength indication error: ≤ 0.005nm
- 1.13 Repeatability: ≤ 0.005nm
- 1.14 Correlation coefficient: ≥ 0.9995
- 1.15 Precision: RSD ≤ 1.0%
- 1.16 Stability: RSD ≤ 2.0%
- 1.17 Measurement range: ultramicro to constant
- 1.18 Detection limit:

Zn≤0.003mg/L

Ni ≤0.010mg/L

Mn ≤0.002mg/L

Cr ≤0.007mg/L

Cu ≤0.007mg/L

Ba≤0.001mg/L



- 1.19 Measurement method: single and multi element sequential measurement
- 1.20 Power: 2.5KW (maximum power consumption)
- 2, Detailed parameters of instrument components
- 1. RF generator
- 1.1 Circuit type: all solid state RF generator
- 1.2 Operating frequency 27.12MHz
- 1.3 Frequency stability: 0.01%
- 1.4 Output power: 700W~1200W, step 50W
- 1.5 Output power stability: 0.1%
- 1.6 Electromagnetic field leakage radiation intensity:<2V/m

#### 2. Injection device

- 2.1 Output working coil: inner diameter 22mm, 3 turns
- 2.2 Rectangular tube: three concentric quartz rectangular tube
- 2.3 Coaxial spray: concentric atomizer
- 2.4 Fog chamber: double cylinder and swirling compound fog chamber to further remove heavy fog droplets and improve aerosol atomization efficiency
- 2.5 Observation position: axial observation
- 2.6 Argon flow
- 2.6.1 Plasma gas: mass flowmeter 0-20L/min, accuracy ± 0.4L/min, stability ± 0.2L/min
- 2.6.2 Auxiliary gas: 0-2 L/min Accuracy ± 0.04L/min, stability ± 0.02L/min
- 2.6.3 Carrier gas: 0-2 L/min Accuracy ± 0.04L/min, stability ± 0.02L/min

# 3. Beam splitter

- 3.1 Optical path: Czerny Turner
- 3.2 Focal length: 1000mm
- 3.3 Grating specification: ion etching holographic grating; Marking density: 2400 lines

/mm, marking area: 80 × 110mm

- 3.4 Reciprocal linear dispersion rate: 0.37nm/mm
- 3.5 Resolution: ≤ 0.015nm
- 3.6 Scanning wavelength range: 190nm~800nm
- 3.7 Minimum step distance of stepping motor drive: 0.0006nm
- 3.8 Exit and entrance slit: 20 µ m
- 3.9 Spec. of reflector: 78 × one hundred and five × 16mm3
- 3.10 Lens: Φ 30mm 1:1 imaging
- 3.11 Spectrometer thermostatic device: 30-38°C adjustable



## 4. Light metering device

- 4.1 Photomultiplier tube specification: R955
- 4.2 Negative high voltage of photomultiplier tube: 200V~1000V, stability < 0.05%
- 4.3 Photomultiplier tube current measurement range: 10-4-10-9A
- 4.4 Signal acquisition mode: V/F conversion

## 5. Instrument configuration

- 5.1 One ICP-7700 host
- 5.2 A set of software installation CD and user manual
- 5.3 A set of host power cable, serial port cable and USB data cable
- 5.4 One computer
- 5.5 One black and white laser printer
- 5.6 One EW-2H cooling water circulating device



#### **HPLC Servicing, Validation, Trainings and Preventive Maintenance:**

HPLC Servicing: HPLC Servicing: We have team of service engineers who can attend to any make of HPLC promptly @the most

affordable cost.

**Trainings** :We also take up preventive Maintenace to reduce downtime of HPLC's Trainings.

AMC's/CMC : AMC's/CMC : We offer user training both in-House and at customer sites on HPLC principles, operations, trouble-

shooting.

Validations : Validations : We have protocols for carrying out periodic Validations as per GLP/GMP/USFDA norms.

Instruments : We offer instruments/Renting Services Modules like pumps, detector etc. on Rent.





#### **About Analytical Technologies**

Analytical Technologies is synonymous for offering technologies for doing analysis and is the Fastest Growing Global Brand having presence in at least 96 countries across the global. Analytical Technologies Limited is an ISO:9001 Certified Company engaged in Designing, Manufaturing, Marketing & providing Services for the Analytical, Chromatography, Spectroscopy, Bio Technology, Bio Medical, Clinical Diagnostics, Material Science & General Laboratory Instrumentation. Analytical Technologies, India has across the Country operations with at least 4 Regional Offices, 6 Branch Offices & Service Centers. Distributors & Channel partners worldwide.

# **Our Products & Technologies**



LCMS



Maldi TOF



Optima Gas Chromatograph



Flash Chromatograph



DAC Column



GCMS 3068



UHPLC



**HPTLC** 



Ion Chromatograph



Production HPLC



HPLC



Column



DLS



Water purification system



#### >>> Corporate Social Responsibility



- 1. Research & Innovation Scientist's awards & International Conferance visit sponsership / QC Professional Awards:
  Quality life is possible by innovation only and the innovation is possible by research only, hence ANALYTICAL FOUNDATION is committed to identify such personallities for their contributions across various field of Science and Technology and awarding them yearly. To participate for award, send us your details of research /testing/ publication at info@analyticalfoundation.org
- 2. Improving quality of life by offering **YOGA Training courses**, **Work shops** / **Seminars** etc.
- 3.**ANALYTICAL FOUNDATION** aims to DETOXIFY human minds, souls and body by means of Yoga, Meditation, Ayurveda, Naturecure, Health Care, Ara, Events, Camps etc.
- ▶ A portion of profit of **ANALYTICAL GROUP** Company's goes into **ANALYTICAL FOUNDATION** for the aboce noble cause.



>>> Reach us @







HPLC Solutions

MultipleLabs

Infinite Multiplelabs LLP

Analytical Bio-Med

Analytical Foundation (Trust)

Corporate & Regd. Office: Analytical House, # E67 & E68, Ravi Park, Vasna Road, Baroda, Gujarat 390 015. INDIA T: +91 265 2253620 +91 265 2252839 +91 265 2252370 F: +91 265 2254395 E :- info@analyticalgroup.net info@hplctechnologies.com info@multiplelabs.com W:- www.analyticalgroup.net www.hplctechnologies.com www.multiplelabs.com Sales & Support Offices: across the country: Distributors & Channel partners World Wide USA| UK| Australia| Dubai| Malaysia

reserves rights to add/delete/modify the contents / technical specifications of the catalogue withou